



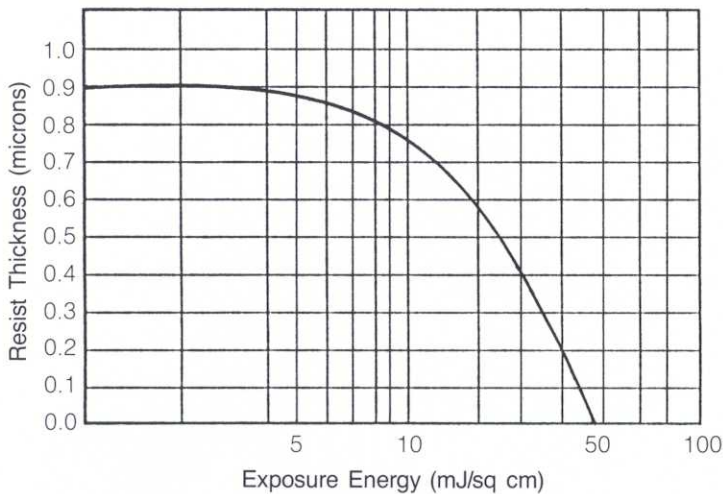
# SHIPLEY

## MICROPOSIT® MF® CD-26 DEVELOPER

MICROPOSIT MF CD-26 DEVELOPER is a metal ion free developer specifically formulated for use with MICROPOSIT S1400® and S1800® SERIES PHOTO RESIST systems. It is recommended for use in wafer fabrication where it is desirable to avoid a potential source of metal ion contamination. Specifically, it is formulated for high resolution immersion developing applications. The unique functional properties of MICROPOSIT MF CD-26 DEVELOPER give high process reliability to integrated circuit fabrication.

- Surfactant free
- Low chloride

CHARACTERISTIC CURVE



MICROPOSIT® MF® CD-26 DEVELOPER  
AND COMPETITIVE RESIST

